Electronic Supplementary Material (ESI) for RSC Advances. This journal is © The Royal Society of Chemistry 2019

Electronic Supplementary Information (ESI)

Covalently Benzimidazole Linked Reduced Graphene Oxide/Polyaniline Nanocomposite as Electrode Material

Arkapal Roy, Saptarshi Dhibar, Sibu Kundu and Sudip Malik*

School of Applied and Interdisciplinary Sciences (Formerly Polymer Science Unit), Indian

Association for the Cultivation of Science, 2A & 2B Raja S. C. Mullick Road, Jadavpur,

Kolkata – 700032, India

| Table of Content: | Page No |
|---|---------|
| a) NMR and FTIR Spectra (Figure S1-S2) | S2 |
| b) XRD study (Figure S3) | S3 |
| c) XPS Study (Figure S4) | S3 |
| d) FESEM Image of GO (Figure S5) | S4 |
| e) CV measurements (Figure S6-S7) | S5 |
| f) GCD measurements (Figure S8-S9) | S6 |
| g) Impedance studies (Figure S10-S11) | S7 |
| h) Comparative data of specific capacitance and capacitance retention for the related rGO& PANI Materials | S8 |

a) NMR and FTIR spectra:



Fig. S1: ¹H-NMR of 1, 3-bis(2'-benzimidazolyl)-5-aminobenzene



Fig. S2: FT-IR Spectra of 1, 3-bis(2'-benzimidazolyl)-5-aminobenzene

b) XRD study:









Fig. S4: (a) XPS survey spectra of GO; (b) deconvoluted C 1s spectra of GO and (c) deconvoluted O 1s spectra of GO

d) FESEM Image of GO:



Fig. S5: FESEM Image of GO

e) CV studies:



Fig. S6: CV study of (a) RGONBZ at 30 mV/s and (b) RGONBZ_PANI_S2 at 10mV/s



Fig. S7: Specific Capacitance vs. Current density plot for RGONBZ and RGONBZ_PANI_S2

f) GCD Studies:



Fig. S8: Charge-Discharge cycle at different current densities of (a) RGONBZ_PANI_S1, (b) RGONBZ_PANI_S3, (c) Specific capacitance vs. charge density plots for the three binary composite materials and (d) Charge –discharge comparison of three different binary composites at 0.2 A/g current densities.



Fig. S9: Plot of peak current vs. scan rate

g) Impedance studies:



Fig. S10: Impedance Spectra of (a) RGONBZ & (b) RGONBZ_PANI_S2



Fig. S11: The equivalent circuit used for the fitting of Nyquist plots (C_{dl} = double layer capacitance, W = Warburg impedance, R_{ct} = Charge-transfer resistance, R_s = Solution resistance, CPE = constant phase element)

h) Comparative data of specific capacitance & capacitance retention for the related rGO & PANI Materials

Table S1: Comparative data of specific capacitance & capacitance retention for the related rGO & PANI Materials

| Materials | Specific Capacitance (F g ⁻¹) | Capacitance Retention | Reference |
|----------------|---|-----------------------|--------------|
| BI-G | 781 at 0.1 A g ⁻¹ | 85% | 1 |
| NG | 301 at 0.1 A g ⁻¹ | 97.1% | 2 |
| GNS/PANI | 532.3 at 2mV/Sec | 99.6% | 3 |
| GO/PANI | 425 at 0.2 A g ⁻¹ | 83% | 4 |
| CFGO-PANI | 525 at 0.3 A g ⁻¹ | 91% | 5 |
| RGONBZ | 477 at 0.2 A g ⁻¹ | 87.9% | Present Work |
| RGONBZ_PANI_S2 | 823 at 0.2 A g ⁻¹ | 77.5% | Present Work |